

Hoch- und Höchstfrequenzhalbleiterschaltungen (HHHS) Millimetre-wave monolithic integrated circuit design

Winter term 2013/2014
lecture overview

INSTITUT FÜR HOCHFREQUENZTECHNIK UND ELEKTRONIK



overview

- Millimetre-wave monolithic integrated circuit (MMIC)
 - a definition
 - features of an MMIC
- reasons for operating in the millimetre-wave regime
 - frequencies, advantages
- mmW and MMIC technologies
- mmW system set-up
 - analogue front-end building blocks
- application examples
- prize considerations

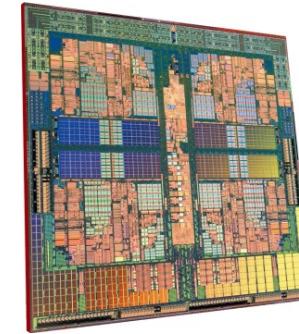
MMIC: a definition

- trad.: monolithic microwave integrated circuit (3...30 GHz)
- at mm-wave frequencies: millimetre-wave monolithic integrated circuit (30... 300 GHz)
- "monolithic" = from Greek “monólithos” = single stone
- “A monolithic microwave integrated circuit is an active or passive microwave circuit formed in situ on a semiconductor substrate by a combination of deposition techniques including diffusion, evaporation, epitaxy, and other means.” Robert A. Pucel
- MMIC versus hybrid mm-wave technologies
 - cost reduction by batch processing
 - higher reliability and improved reproducibility
 - size and weight reduction
 - circuit design flexibility and multifunction performance
 - multi-octave operation

MMIC: a definition by comparison

- **IC** integrated circuit

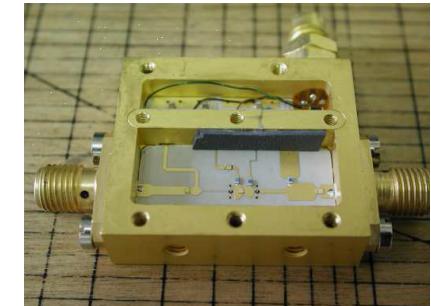
- term used today for digital circuits
- 45/65/... nm Si-CMOS
- billions of transistors
- many levels of metal interconnect layers (visible on surface)



AMD Phenom (2007)
65 nm SOI CMOS
image: wikipedia

- **MIC** micro/millimetre-wave integrated circuit

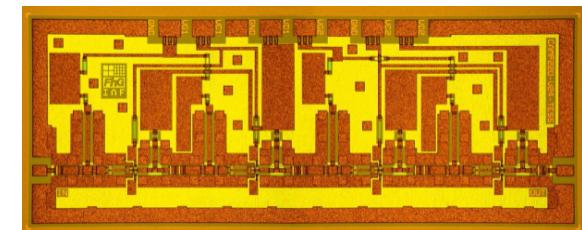
- hybrid combination of active and passive components on a substrate (circuit board)
- alumina Al₂O₃
- LTCC (low-temperature cofired ceramics)
- soft-board, ...



4-8 GHz cryo-LNA MIC

- **MMIC** micro/millimetre-wave integrated circuit

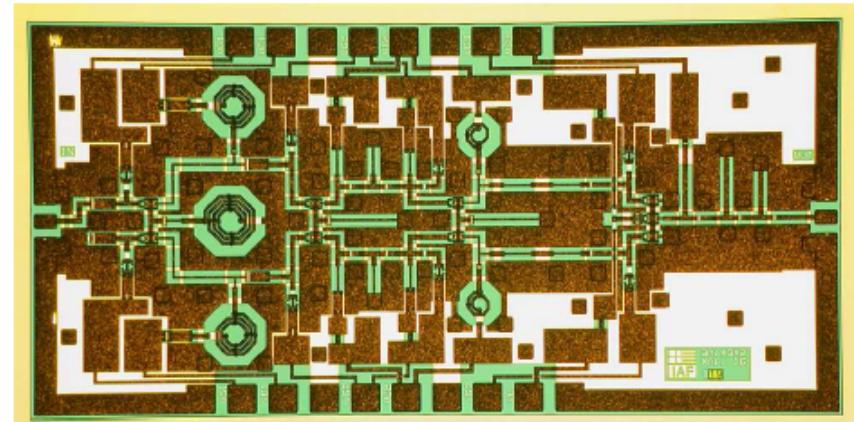
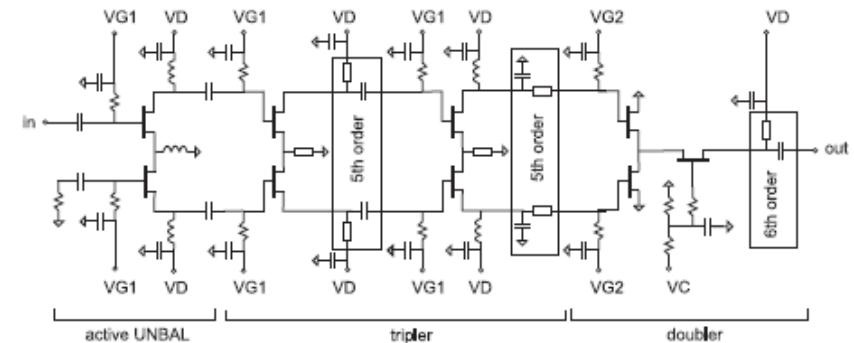
- all circuit components on a single chip
- S-MMIC: sub-millimetre-wave (>300 GHz) operation



220 GHz LNA, Fraunhofer IAF

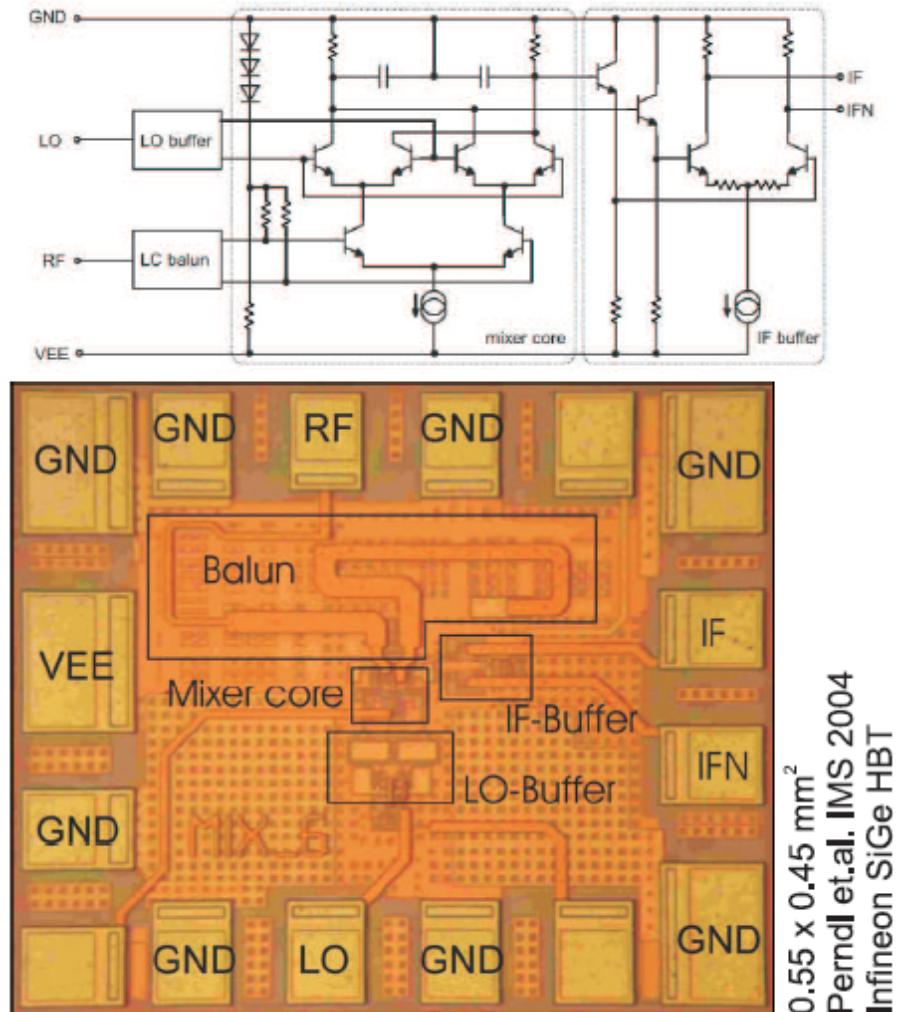
The “classic” MMIC

- features
 - III-V-based (GaAs, InP, GaN)
 - low integration density / large chip size
 - extensive use of reactive elements (matching, coupling, biasing...)
 - inter-stage matching
 - passives as distributed elements (transmission lines)
 - few levels (typically two) of metal interconnect layers



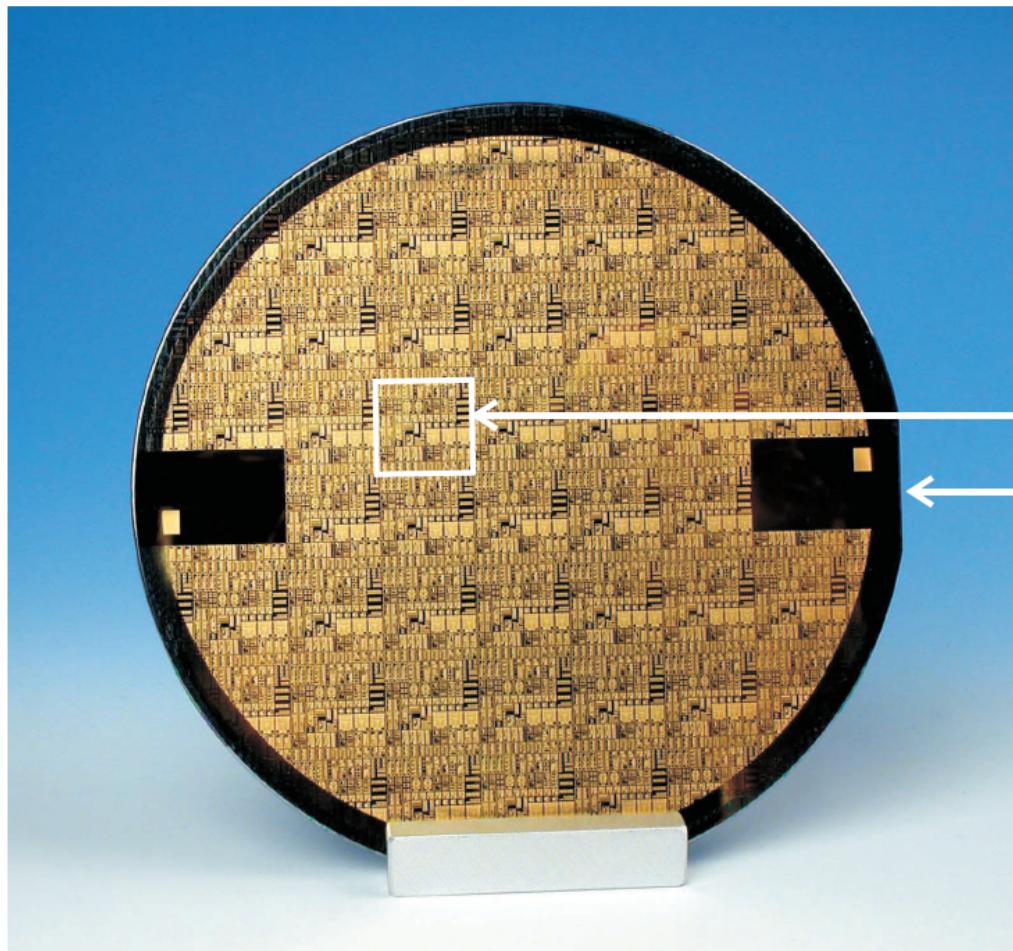
The “new” MMIC

- features
 - Si-based (SiGe HBT, Si CMOS)
 - high integration density / small chip size
 - limited use of reactive elements (transmission lines)
 - often differential topologies
 - in highly compact circuits (e.g. Gilbert cells), use of active impedance transformers



processed wafer

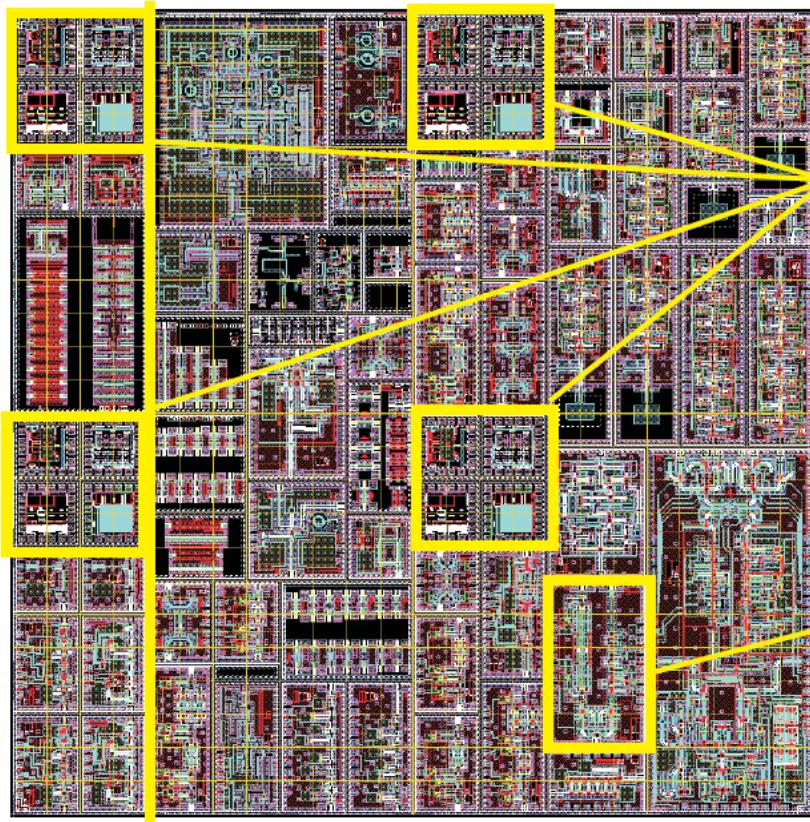
- 4" GaAs wafer



stepper cell
flat

mask layout

- “pizza” mask
- e.g. 1.2 x 1.2 mm²



process control monitors (PCM)

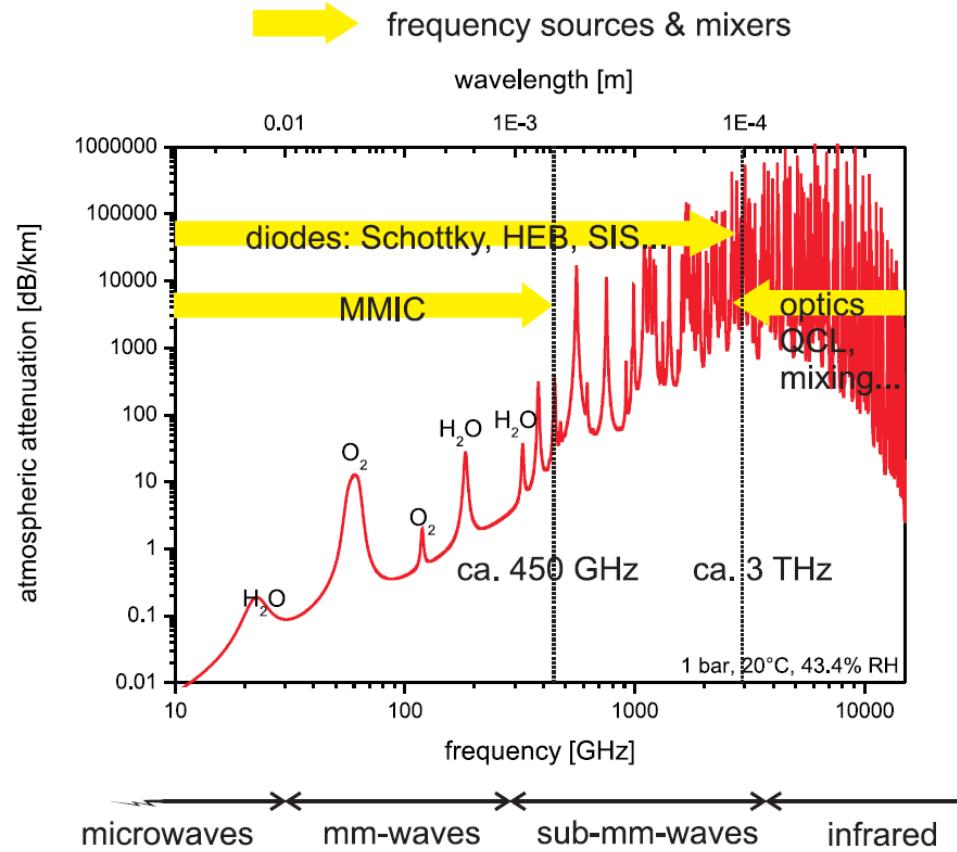
MMIC

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electromagnetic spectrum: the “THz gap”

- microwave
 - 3 - 30 GHz
 - 10 - 1 cm free-space wavelength
- millimetre-wave
 - 30 - 300 GHz
 - 10 - 1 mm free-space wavelength
- sub-millimetre-wave
 - new term
 - MMICs operating beyond 300 GHz
- “THz”
 - loosely used in the literature
 - here: 0.1 - 10 THz
- infrared
 - Near-infrared (NIR): 0.75-1.4 μm
 - Short-wavelength infrared (SWIR): 1.4-3 μm
 - Mid-wavelength infrared (MWIR) also called intermediate infrared (IIR): 3-8 μm
 - Long-wavelength infrared (LWIR): 8-15 μm
 - Far infrared (FIR): 15-1,000 μm



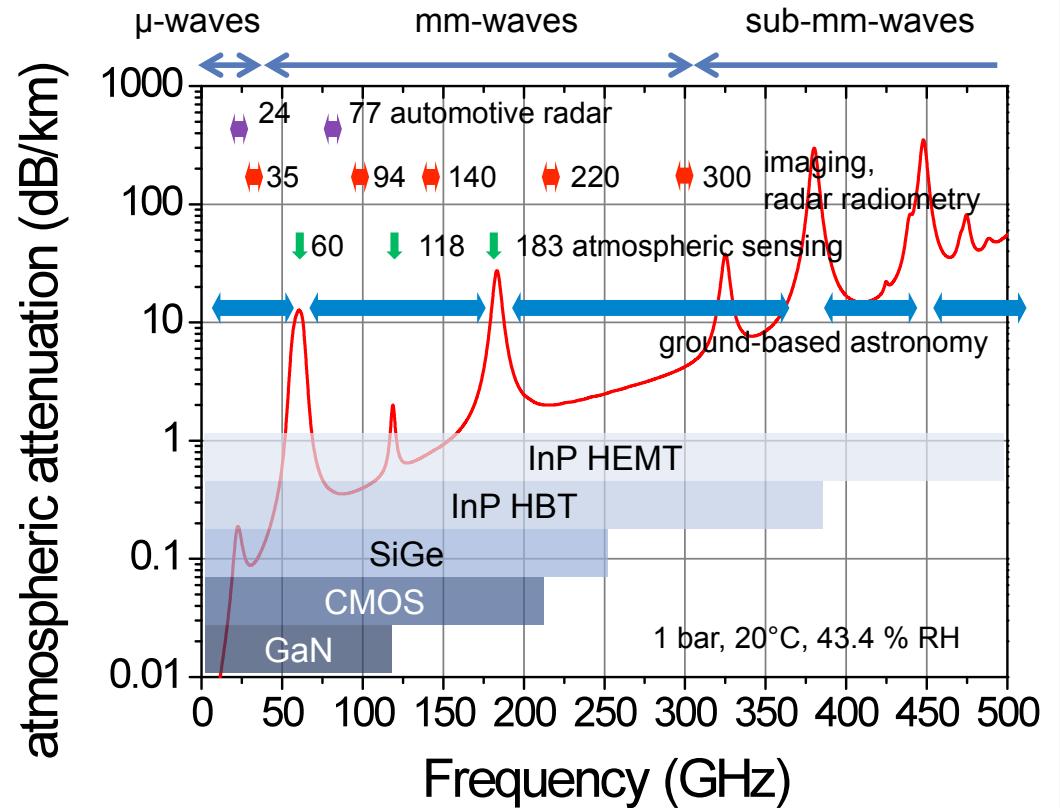
THz technologies

■ advantages and disadvantages

	Optics	Cryogenic diodes (HEB, SIS)	Schottky diodes	MMIC
THz operation (0.1 – 1 THz)	feasible	feasible	feasible	limited
Mass manufacturability (batch processing, packaging, testing, ...)	feasible	feasible	impossible	feasible
ease of deployment (size, weight, temp. stabilisation, ...)	limited	impossible	feasible	feasible
multi-functional integration (generation, amplification, conversion, ...)	impossible	impossible	impossible	feasible
miniaturisation (module form factor, multi-channel, ...)	feasible	feasible	impossible	feasible

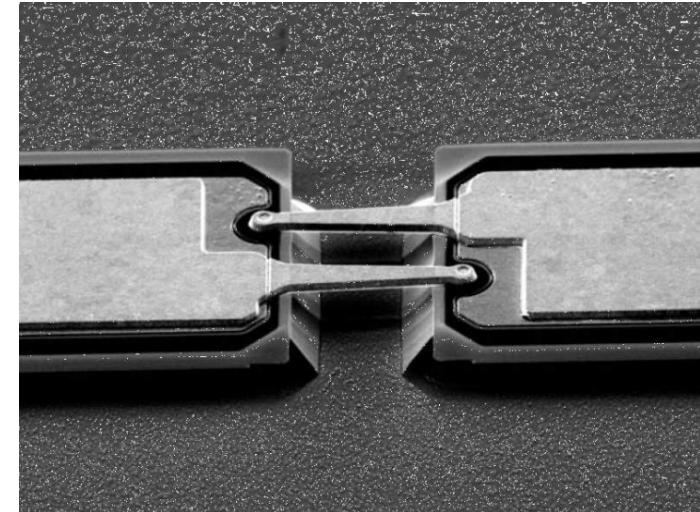
EM spectrum: frequencies and applications

- spectroscopy
 - detect and monitor molecule absorption frequencies in mm-wave region
 - meteorology, atmospheric sensing, medical...
- mm-wave ranging and imaging
 - non-ionizing radiation penetrates clothing, adverse weather, packaging material
 - radar, safety & security, concealed weapon detection, avionics (landing aid, runway control)...
- higher frequencies = larger absolute bandwidths
 - high data rate communication systems
 - high geometrical resolution in radar



Schottky diodes: passive nonlinear circuits

- features
 - the classic millimetre-wave technology
 - dedicated processes not compatible with transistor technologies
- major applications
 - frequency multipliers and mixers beyond 100GHz
 - to-date up to >3 THz



Anti-parallel Schottky diodes
(Rutherford Appleton Lab, UK)

semiconductor technologies

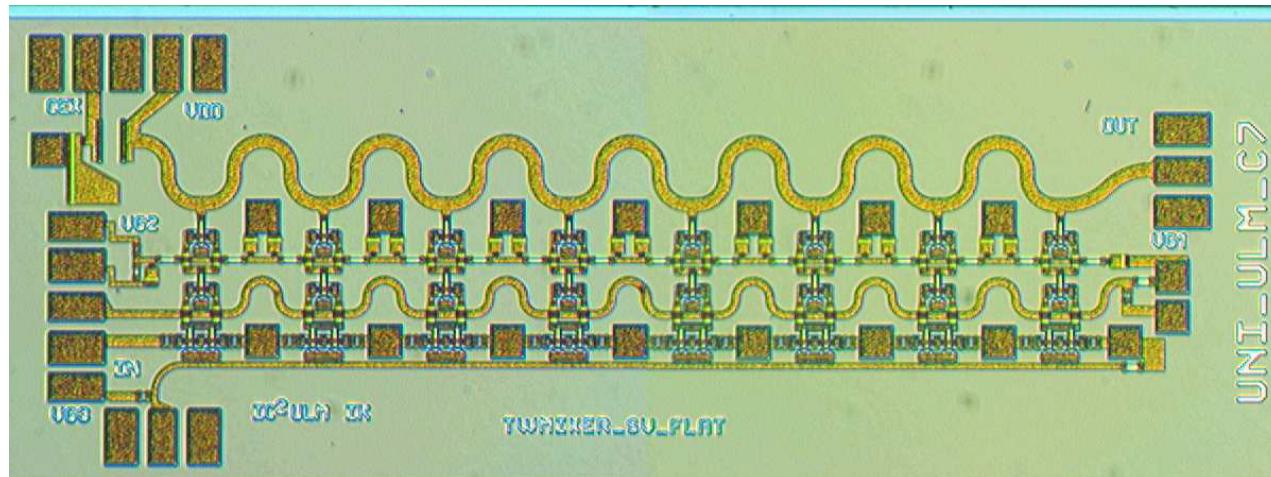
- HEMT: high electron mobility transistor
- (D-)HBT: (double) hetero-structure bipolar transistor
- CMOS: complementary metal-oxide-semiconductor

	field effect transistor (FET)	bipolar junction transistor (BJT)
III-V-based	GaAs (pseudomorphic) HEMT InP (pseudomorphic) HEMT GaAs metamorphic HEMT	GaAs HBT InP (D-)HBT
Si-based	(RF-) CMOS	SiGe HBT

GaAs pHEMT

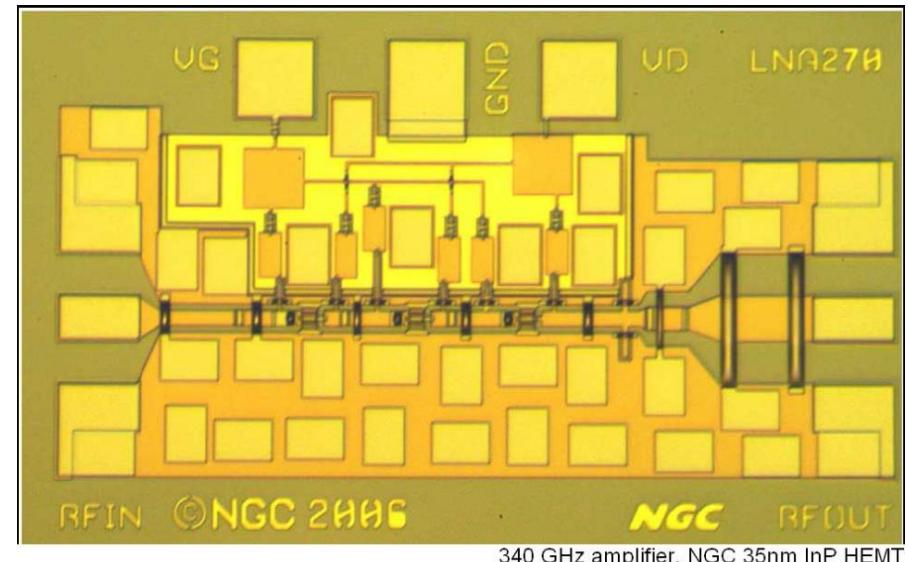
■ features

- the “classic” HEMT technology
- many foundries worldwide
- typically 4-6 inch wafers
- major MMIC applications
- analogue frontends (incl. LNA, mixer, PA) up to >100GHz
- automotive + military radar
- communication



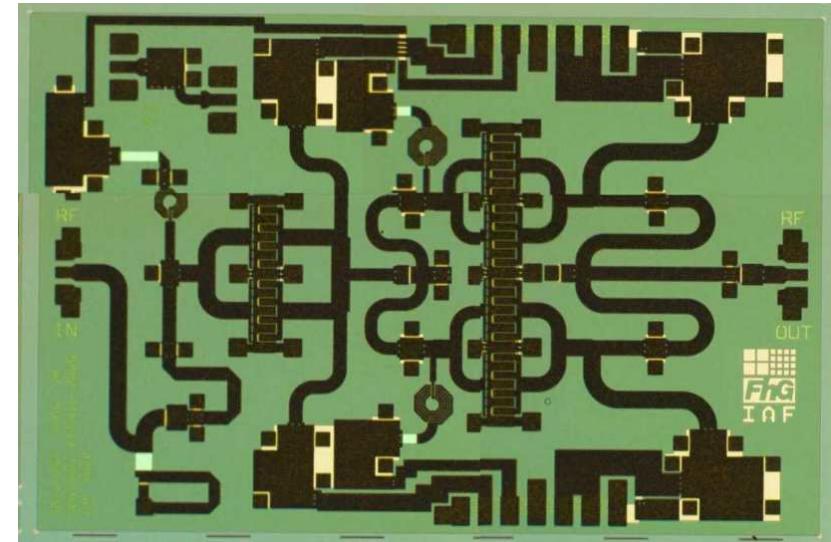
InP HEMT

- features
 - (+) highest MMIC performance to-date
 - (-) InP substrate: brittle, max. 4", costly
- major MMIC applications
 - ultra low-noise amplifiers
 - analogue frontends beyond 100GHz
 - radio-astronomy, mm-wave imaging
- metamorphic HEMT
 - InP HEMT on GaAs substrate
 - combine InP performance and advantageous GaAs substrates (prize, size, handling)



GaN HEMT

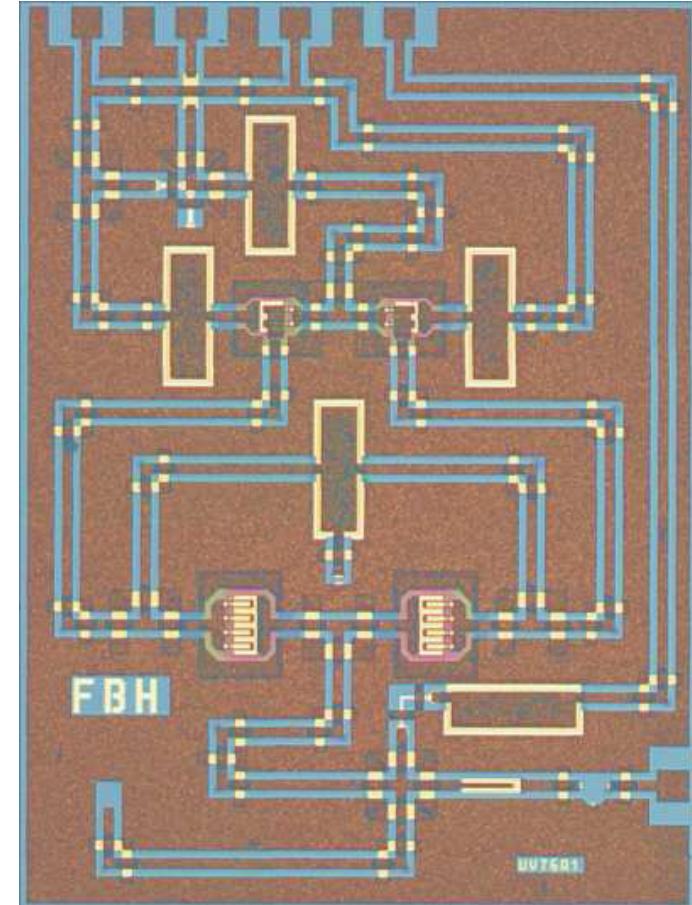
- features
 - high breakdown voltage
 - high speed
 - on 4" SiC wafers
- major MMIC applications
 - high efficiency and broadband power amplifiers up to Ka-band
 - base stations
 - radar



GaN X-band (10 GHz) power amplifier

GaAs HBT

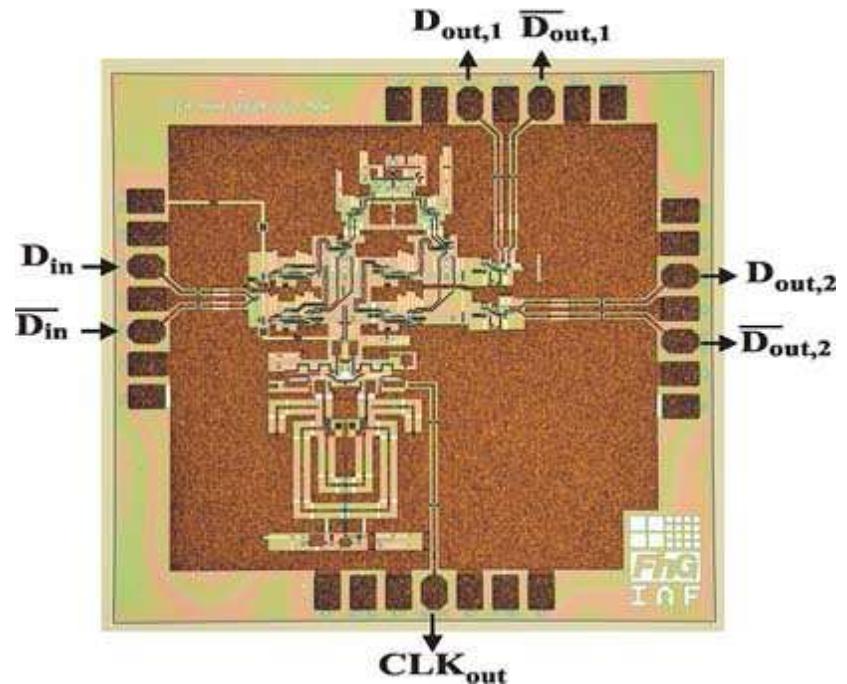
- features
 - high breakdown voltage
- major MMIC applications
 - power amplifiers
 - low phase-noise frequency sources (VCO)



76 GHz VCO, GaAs HBT FBH Berlin

InP (D)HBT

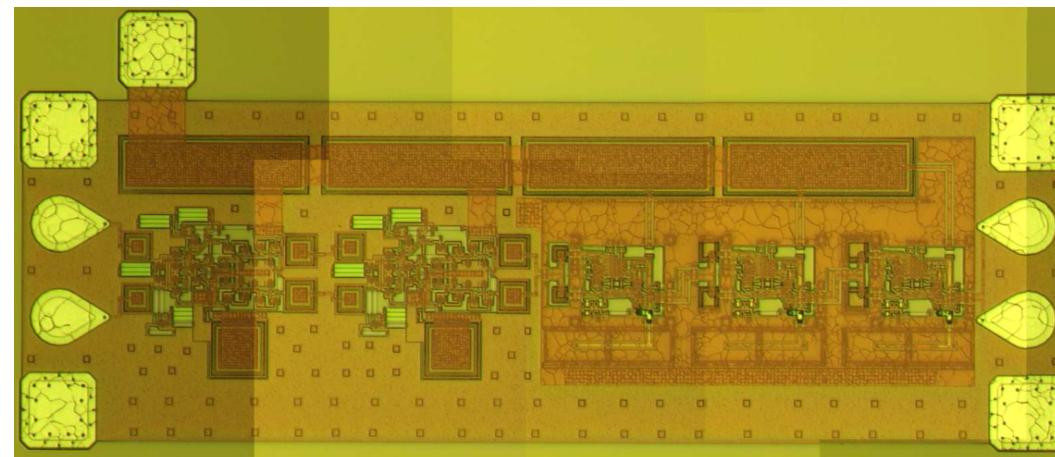
- features
 - high breakdown voltage
 - OEIC (opto-electronic integrated circuit): integrate with photodiode...
- major MMIC applications
 - mixed-signal circuits
 - optical communication systems (100 Gbit ethernet)
 - fast ADC/DAC



InP DHBT 80Gbps clock and data recovery

SiGe HBT

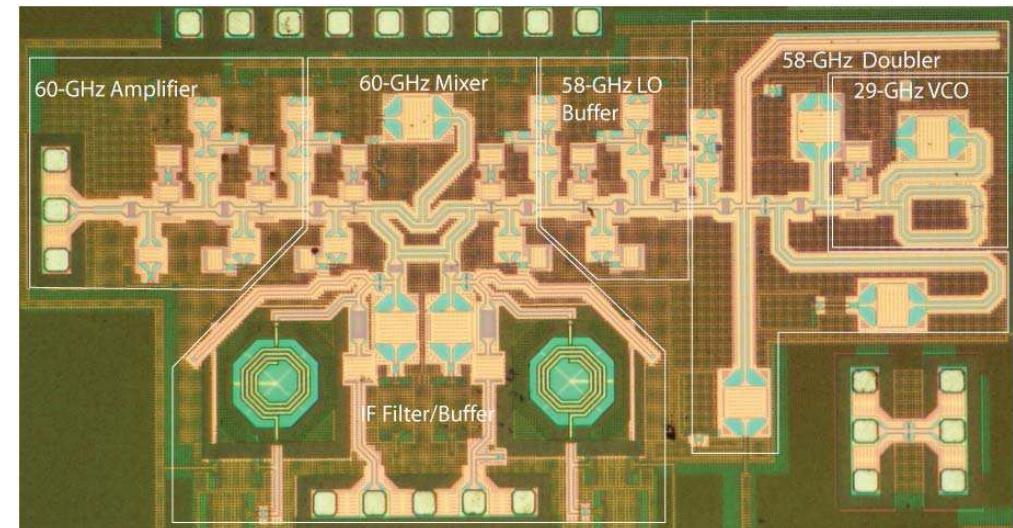
- features
 - high frequency capability
 - comes in BiCMOS processes
 - high integration density
- major MMIC applications
 - analog up to 77GHz
 - mixed signal: e.g. fast ADC/DAC



>40GHz 32:1 frequency divider (Chartier, Atmel SiGe HBT)

(RF-) CMOS

- features
 - fast increasing high frequency capability
 - highest integration density
 - mass market driven
 - RF-CMOS for higher breakdown voltages
 - 8"-12" wafers
- major MMIC applications
 - analogue up to 77GHz
- mixed signal: e.g. fast ADC/DAC

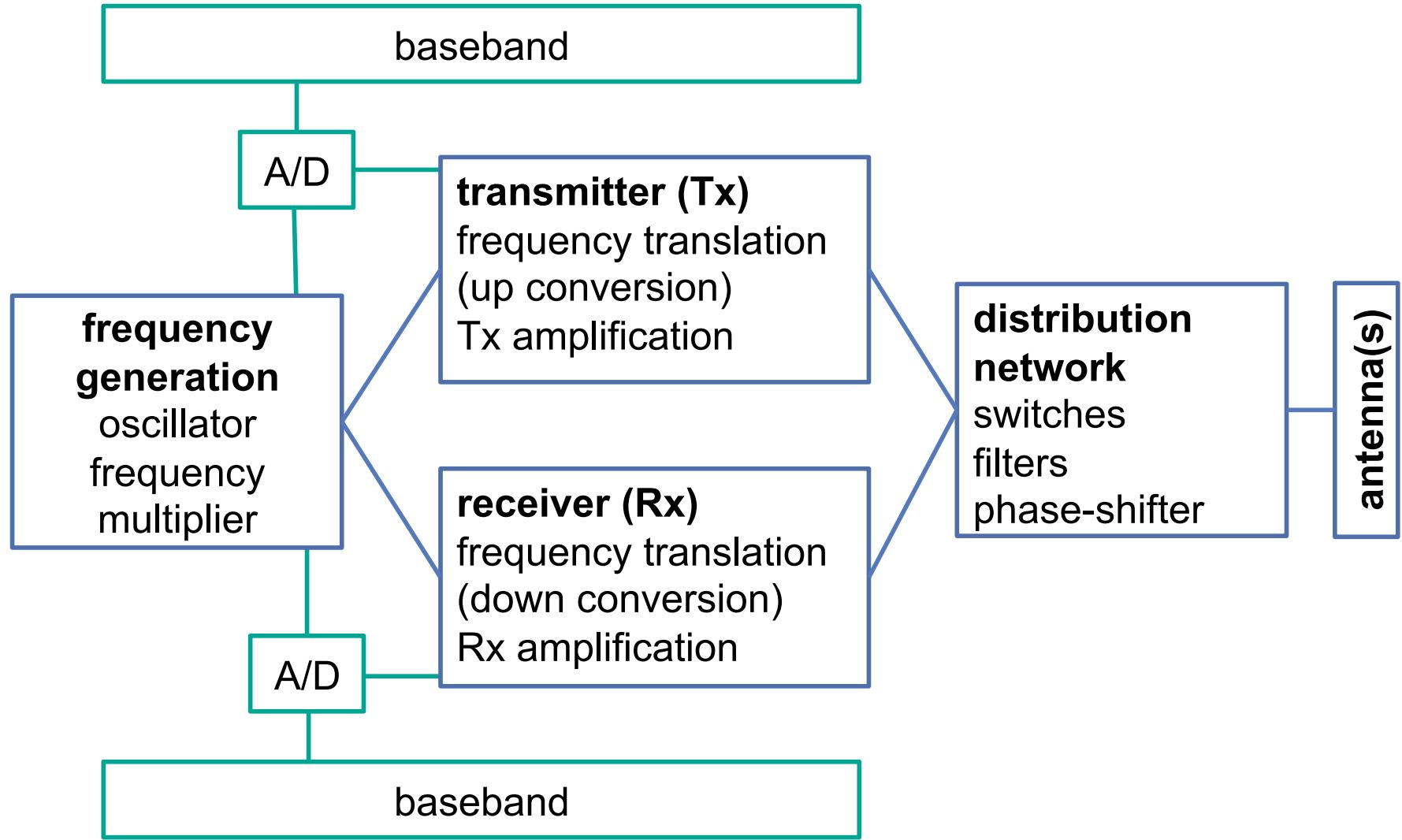


60 GHz Rx, 130nm CMOS ST Microelectronics
 (Niknejad et.al CSICS 2007)

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- application examples
- prize considerations

analogue front-end



building blocks: frequency generation

- radar
 - transmission signal
 - modulated: frequency-modulated continuous wave (FMCW), AM,...
 - pulsed
- communication
 - local oscillator (LO) for up- and down-conversion in mixers
 - fixed frequency or multiple carriers
- architectures
 - fundamental oscillator with phase-locked loop (PLL) stabilisation (phase noise reduction of free-running oscillator)
 - sub-harmonic oscillator with frequency multiplication

building blocks: frequency translation

- down-conversion
 - in communication systems: mixer to convert from RF to IF
 - in sensor systems (active and passive)
 - homodyne (mix with transmit signal, e.g. radar) or heterodyne (mix with LO) architectures
 - zero-IF or super-heterodyne receivers
 - direct detection: total power measurement by detector diode with (= zero-IF) or without down-conversion

- up-conversion
 - in communication and data transfer systems: mixer to convert from IF to RF
 - in radar: up-convert FMCW chirp signal generated at lower frequencies

building blocks: distribution network

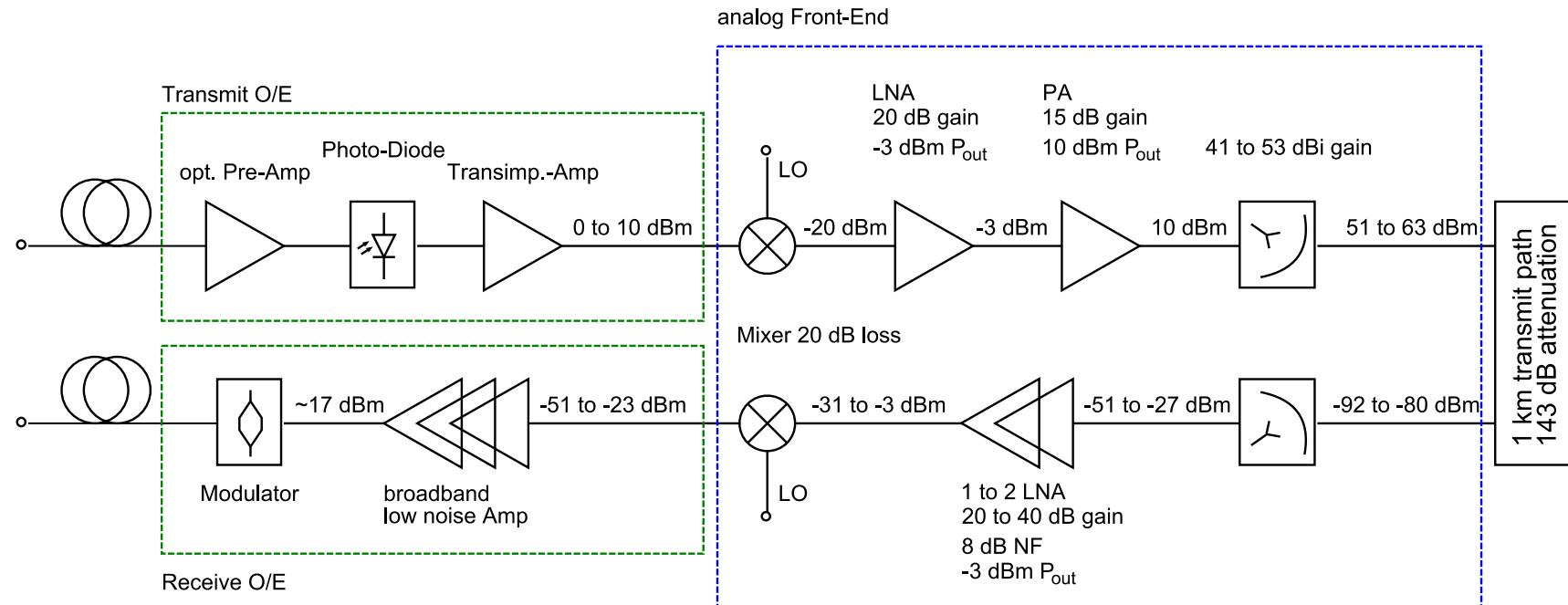
- radiometers
 - Dicke switch
 - active, passive / hot, cold loads
 - polarisation selectivity
- radars
 - mono- or bi-static
 - phased-arrays
 - electronic beam steering
- communication
 - single input single output (SISO)
 - multiple input multiple output (MIMO)
 - antenna switch (Rx, Tx)

building blocks: signal amplification

- receiver
 - low noise amplifier (LNA)
 - noise figure, gain, ...
- transmitter
 - power amplifier
 - efficiency, output power, linearity, ...
- baseband
 - broadband amplifier
 - bandwidth dependent on
 - radar FMCW ramp
 - communication data-rate

link budget calculations

- define IN/OUT power level, system range, margin, ...
 - define antenna gain, LNA noise figure and gain, PA gain and power, ...
 - are means to prevent malfunction necessary?
 - redundancy, peak power stability, ...

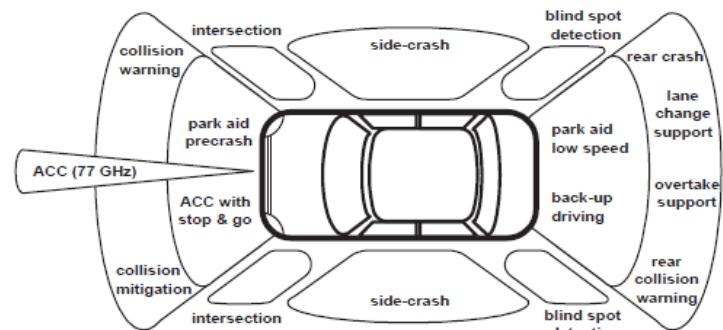
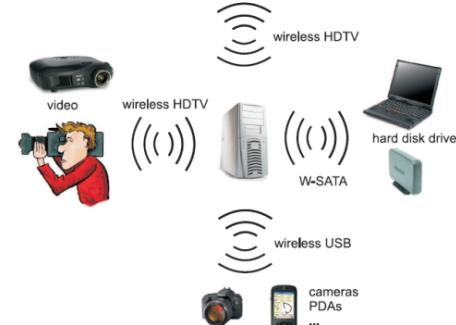


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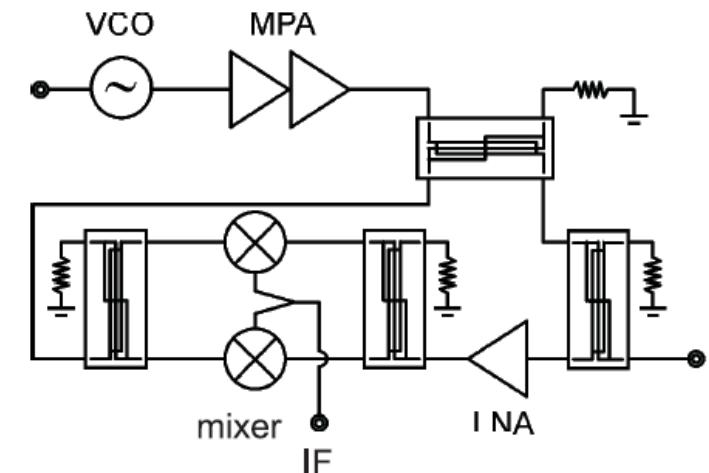
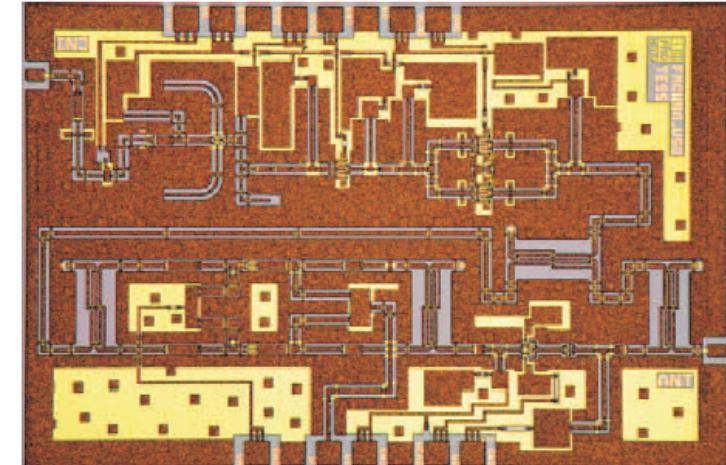
MMIC applications: commercial

- 60 GHz wireless comm.
 - wireless data rates up to 10Gbps
 - freq. allocation: 57-66GHz
 - application scenarios
 - home theatre (HDT)
 - Gbit WLAN
 - media kiosk
 - medical imaging (e.g. MRI)
 - fast data synchronisation
 - car-to-X communication
- 24 and 77 GHz automotive radar
- sensing and radar for security
 - body scanner “Nacktscanner”



MMIC applications: 94 GHz FMCW radar

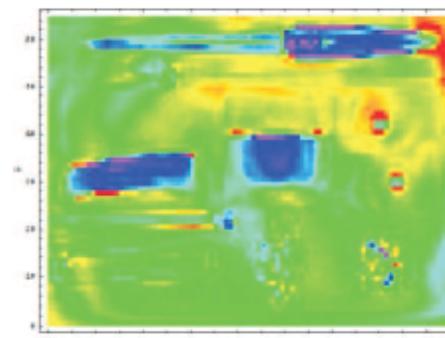
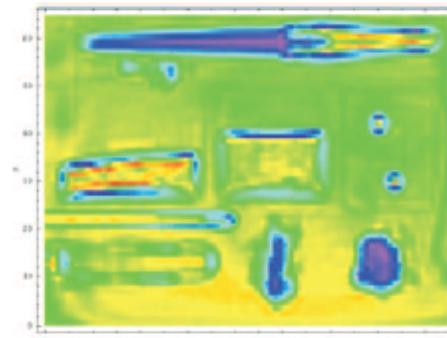
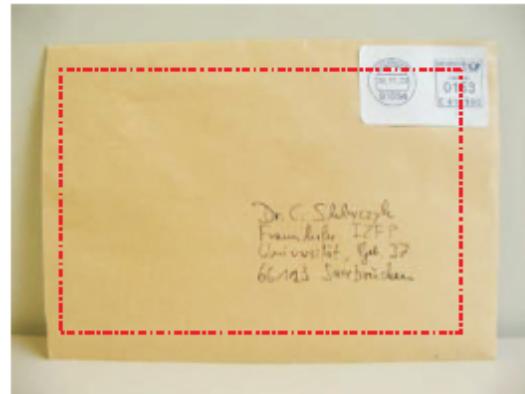
- transmitter
 - voltage-controlled oscillator
 - medium power amplifier
 - Lange-coupler
- receiver
 - Lange-coupler
 - low-noise amplifier
 - balanced mixer
- helicopter landing aid (brown-out)
- surveillance (e.g. in UAVs)
- material inspection
- ranging and localisation
- visual aid for fire fighting



94 GHz FMCW, Fraunhofer IAF

MMIC applications: 94 GHz imaging

- mm-waves penetrate packaging and clothing
- detection and localisation of metallic and non-metallic items



FMCW radar images at 94 GHz

- Nail file
- Sugar in portion pack
- Sugar in plastic bag
- Sweetener
- Cocktail needle
- Copper wire
- Paper clip
- Amplitude (left)
- Phase (right)

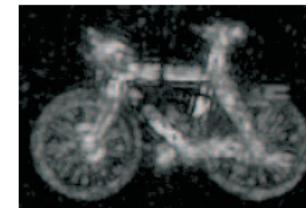
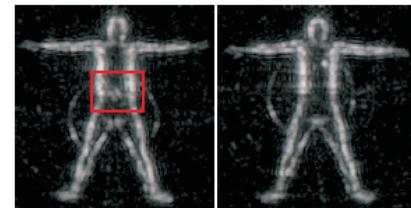
MMIC applications: 210 GHz FMCW radar

- Fraunhofer FHR COBRA 210 GHz FMCW radar
 - linear chirp FMCW w/ chirp length $\Delta f = 8$ GHz
 - bandwidth: 8 GHz
- higher radar bandwidth results in higher geometrical resolution
- ISAR scenario: distance 150 m, height 1.5 m, turntable 10° tilted

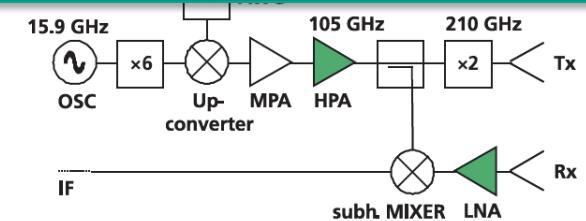
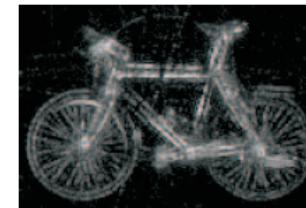
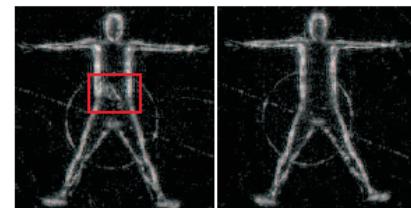
photo



94 GHz
bw = 4 GHz
 $\Delta R = 3.5$ cm



210 GHz
bw = 8 GHz
 $\Delta R = 1.8$ cm

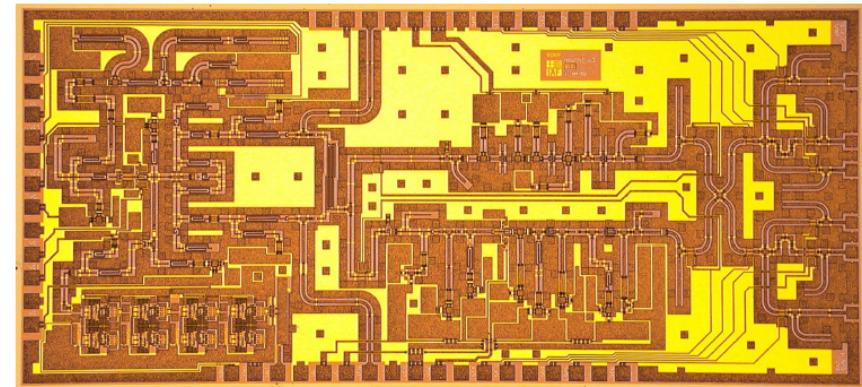


FGAN **FHR** 210 GHz FMCW "COBRA"

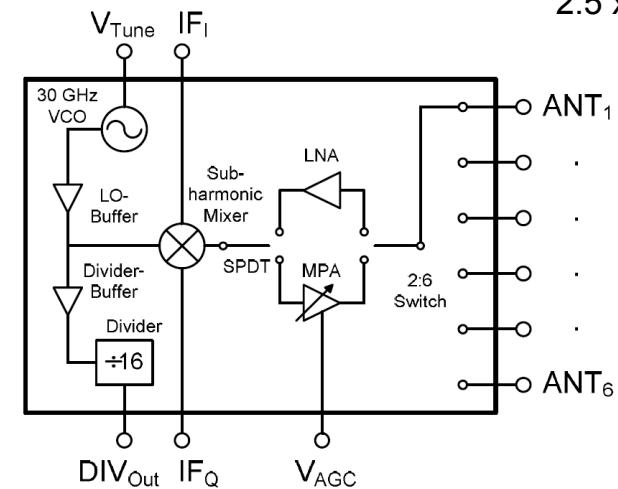
MMIC applications: 60 GHz wireless comm.

- single-chip Rx/Tx
- Fraunhofer IAF 100 nm gate-length mHEMT
- Operating frequency range
 - RF: 55 – 65 GHz
 - IF: DC – 3 GHz
- MMIC building blocks
 - SPDT and 2:6 switch
 - noise amplifier (LNA)
 - variable gain medium power amplifier (MPA)
 - sub-harmonic resistive IQ-mixer
 - voltage controlled oscillator (VCO)
 - LO / divider buffer amplifier
 - static divider (4 times by 2)

Koch et. al: A Fully Integrated, Compound Transceiver MIMIC utilizing Six Antenna Ports for 60 GHz Wireless Applications

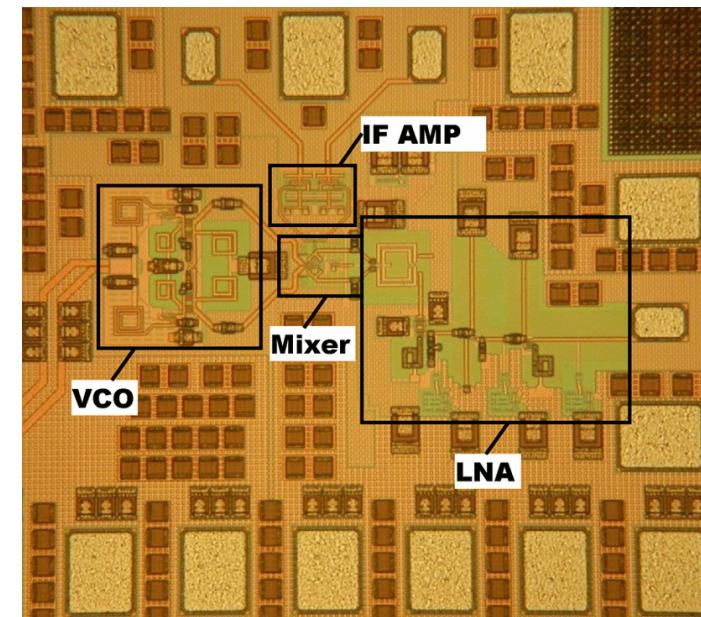
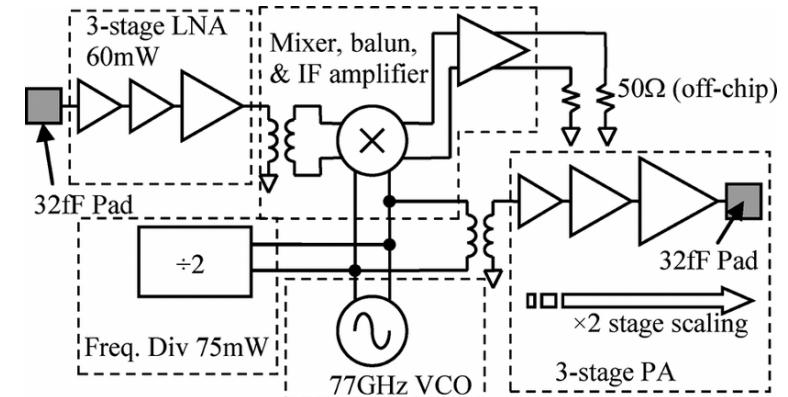


2.5 x 5.5 mm²



MMIC applications: 77 GHz automotive radar

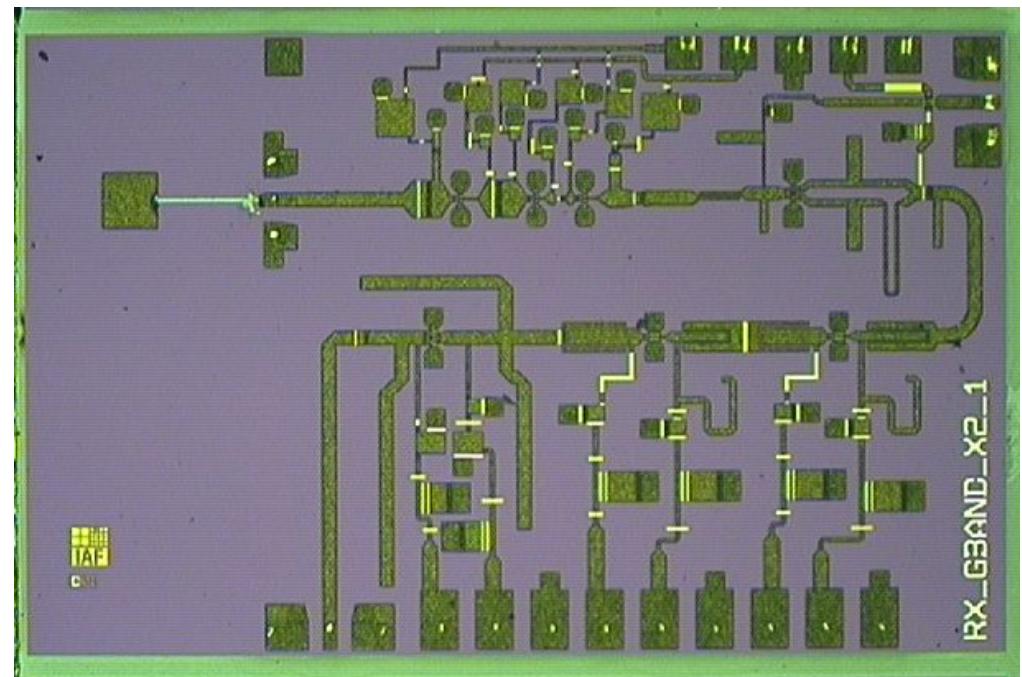
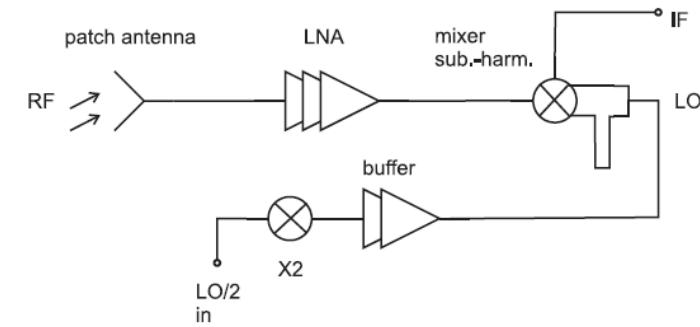
- Doppler radar and imaging applications
- fabricated in SiGe HBT and SiGe BiCMOS technologies
- 65 nm CMOS
- conventional MMIC technique using thin-film microstrip (TFM) transmission line matching
- MMIC building blocks
 - double-balanced mixer
 - IF amplifier
 - VCO
 - power amplifier
 - LNA



Nicolson et. al.: A Low-Voltage SiGe BiCMOS
77-GHz Automotive Radar Chipset

MMIC applications: 210 GHz imaging

- IAF Fraunhofer 100 nm InAlAs/InGaAs mHEMT
- 50 μm thick GaAs substrate
- microstrip transmission lines with transistor source via-holes
- operating frequency range
 - RF: 195 – 225 GHz
 - IF: 2 GHz
- MMIC building blocks
 - LO frequency doubler
 - 2-stage buffer amplifier
 - subharmonic resistive mixer
 - 3-stage low-noise amplifier
 - on-chip patch antenna



Zirath et. al.: Integrated receivers up to 220 GHz utilizing GaAs-mHEMT technology

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market considerations

- millimetre-wave market structure
 - highly fragmented
 - many niche applications: earth, life, material science...
 - many professional/industrial applications: production...
 - many military applications, some dual-use: aeronautics, safety & security...
 - few consumer, mass market applications
- the potential “killer” application: candidates for mass markets
 - automotive radar
 - 60 GHz wireless (“home theatre” etc.)

price considerations per unit area

- technology cost per unit area
→ what can be done in silicon, will be done in silicon!

substrate	device	cost (\$/mm ²)
Si	CMOS	~ 0.01
SiGe	HBT	0.1 – 0.5
GaAs	HEMT	1 – 2
InP	HEMT	10

- further considerations
 - cost for assembly and testing is comparable for all technologies
 - Si allows for on-chip integration of digital baseband functionalities
 - at mm-waves, cost for mounting, packaging and assembly becomes dominant
→ mm-wave applications for mass markets require low-cost packaging

prize considerations: mask-set cost

- mask-set cost

→ Si-based technologies require mass market (communication, automotive) to be prize-competitive

device	cost (€ / mask-set)
Si-CMOS	> 1 mio
SiGe-HBT	> 100,000
3-5 HEMT	10,000

- further considerations

- design cycle: roughly 2 months production time + design and testing for all technologies
- Si-based technologies are processed in batches (~20 wafers, 8"-12") per run
- GaAs-based technologies are processed by lots (4-6 wafers, 3"-6") per run, e-beam writing of individual wafers

prize considerations: cost vs. #MMIC

- research an development
 - ~100 pieces
- prototyping
 - ~1000 pieces
- products
 - consumer
>> 1 mio. per year
 - professional
> 100,000 per year

